Notice of References Cited Application/Control No. 10/590,079 Examiner BRYAN D. RIPA Applicant(s)/Patent Under Reexamination GOTO ET AL. Page 1 of 1

U.S. PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Name | Classification |
|---|---|--|-----------------|--------------|----------------|
| * | Α | US-6,471,745 | 10-2002 | Foley et al. | 95/54 |
| * | В | US-7,097,875 | 08-2006 | Clyde et al. | 427/115 |
| | U | US- | | | |
| | ם | US- | | | |
| | ш | US- | | | |
| | F | US- | | | |
| | O | US- | | | |
| | Ι | US- | | | |
| | _ | US- | | | |
| | ٦ | US- | | | |
| | K | US- | | | |
| | ┙ | US- | | | |
| | М | US- | | | |

FOREIGN PATENT DOCUMENTS

| * | | Document Number Country Code-Number-Kind Code | Date MM-YYYY | Country | Name | Classification |
|---|---|--|-----------------|---------|------|----------------|
| | N | | | | | |
| | 0 | | | | | |
| | Р | | | | | |
| | Q | | | | | |
| | R | | | | | |
| | S | | | | | |
| | Т | | | | | |

NON-PATENT DOCUMENTS

| * | | Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages) | | | | | |
|---|---|--|--|--|--|--|--|
| | U | Smith et al., "Evaluation of Precursors for Chemical Vapor Deposition of Ruthenium" Thin Solid Films 376, pages 73-81 (2000) | | | | | |
| | > | Goto et al., "Electrochemical Properties of Iridium-Carbon Nano Composite Films Prepared by MOCVD" Scripta Materialia 44, pages 1187-1190 (2001) | | | | | |
| | w | Kimura et al., "Preparation of RuO2-YSZ Nano-Composite Films by MOCVD" Surface and Coatings Technology 167, pages 240-244 (2003) | | | | | |
| | х | | | | | | |

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.